

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Toru Kimura et al.	Confirmation No.: 4887
Application No.: 10/586,187	Group Art Unit: 1722
Filed: July 31, 2007	Examiner: JOHNSON, CONNIE P.
Attorney Docket No.: 01115_1013	

For: UPPER LAYER FILM FORMING COMPOSITION FOR LIQUID IMMERSION
AND METHOD OF FORMING PHOTORESIST PATTERN

MAIL STOP AF

Commissioner for Patents
Alexandria, VA 22313-1450

OK TO ENTER: /C.J./ (12/28/2010)

RESPONSE UNDER 37 C.F.R. § 1.116

Dear Sir:

The following Amendment and Remarks are submitted in response to the Office Action dated September 22, 2010.

AMENDMENT AND PRESENTATION OF CLAIMS 2

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